

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Divisional Patent Application of)	
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Genji IMAI et al.)	Group Art Unit: Unassigned
)	
Division of Application No. 09/418,368)	Examiner: Unassigned
)	
Filed: July 28, 2003)	
)	
For: POSITIVE SENSITIVE RESIN)	
COMPOSITION AND A PROCESS)	
FOR FORMING A RESIST PATTERN)	
THEREWITH)	

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Prior to calculation of the filing fee and examination, please amend the above-identified patent application in the following manner: